ABSTRACT

A semiconductor laser device having a waveguide constructed in a stack of layers including, on a substrate (101) transparent and having a refractive index $n_{\rm e}$ for laser light, a first clad layer (103) of a refractive index $n_{\rm el}$, a second clad layer (104) of a refractive index $n_{\rm e2}$, a third clad layer (105) of a refractive index $n_{\rm e3}$, a first conductivity type guide layer (105) of a refractive index $n_{\rm g}$, an active quantum well layer (107), a second conductivity type guide layer (109), a second conductivity type clad layer (110), and a second conductivity type contact layer (111) deposited in this order, wherein the waveguide has an effective refractive index $n_{\rm e}$, and a relationship of $n_{\rm e2} < (n_{\rm e1}, n_{\rm e3}) < n_{\rm e} < (n_{\rm e}, n_{\rm g})$ is satisfied.

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